Hi-Dow Electron Technology (Hefei) Inc., Ltd.

November 12, 2024

Nemko North America, Inc.
303 River Road
Ottawa, Ontario, Canada
K1V 1H2

REQUEST FOR CONFIDENTIALITY - FCC

FCC ID: 2ACD4HD-18ARX

Pursuant to Sections 0.457(d) and 0.459 of the Commission's Rules and FCC Guidance document 726920, we hereby request permanent confidential treatment of exhibits identified as such in the table below and request they are permanently withheld from public review based on the documents containing trade secrets and proprietary information not customarily released to the public. The public disclosure of this information might be harmful to the applicant and provide unjustified benefits to its competitors.

Exhibit	Type of Confidentiality Requested	
Block Diagrams	☒ Permanent	☐ Short Term
External Photos	----------	☐ Short Term
Internal Photos	☐ Permanent*	☐ Short Term
Operation Description	☒ Permanent	☐ Short Term
Parts List & Placement/BOM	☐ Permanent	☐ Short Term
Tune-Up Procedure	☐ Permanent	☐ Short Term
Schematic Diagrams	☒ Permanent	☐ Short Term
Test Setup Photos	----------	☐ Short Term
User's Manual	☐ Permanent*	☐ Short Term

The asterisked items (*) require further information to be provided in this justification letter before permanent confidentiality will be extended to these exhibits. Please refer to FCC KDB 726920 D01 found at: https://apps.fcc.gov/oetcf/kdb/forms/FTSSearchResultPage.cfm?switch=P&id=41731 and review section II, 3) regarding specific information that must accompany these requests.

Note: any documents held under the Short-Term confidentiality will automatically become public after the requested time if an appropriate extension request has not been received. Any exhibits (i.e., schematic diagrams) that may have already been requested to have "Permanent" confidentiality as shown above need not be repeated under Short-Term confidentiality request.

Sincerely,

Signed: Yang Chen

Printed name: Yang Chen

Title: -

Company Name: Hi-Dow Electron Technology (Hefei) Inc., Ltd.